

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

: Theodore M. Bloomstein

Application No. : 09/922,973

Filed

: August 6, 2001

Entitled

: STEREOLITHOGRAPHIC

PATTERNING WITH VARIABLE

SIZE EXPOSURE AREAS

Docket No.

: 101328-160

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Engellen er Reg. No. 28,711

Group Art Unit: 1756

Examiner: Kripa Sagar

Autorney for Applicant(s)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Applicant herewith makes of record the enclosed references in accordance with §1.97(c) and (e)(2). These documents are cited on the enclosed PTO Form-1449, and a copy of each document cited thereon are enclosed as well.

The undersigned hereby certifies that no item of information contained in the Supplemental Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application, and, to my knowledge, after making reasonable inquiry, no item of information contained in the Supplemental Information Disclosure Statement was known to any individual designated in § 1.56(c) more than three months prior to the filing of

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this Supplemental Information Disclosure Statement. No additional costs are believed to be due in connection with the filing of this Supplemental Information Disclosure Statement. However, please charge any necessary fees in connection with the enclosed statement to our Deposit Account No. 141449.

Date: 8 Odoba 2003

Thomas J. Engellenner

Reg. No. 28,71/1

Respectfully submi

Attorney for Applicant(s)

Nutter, McClennen & Fish, LLP 155 Seaport Blvd. World Trade Center West Boston, MA 02210-2604

Tel: (617)439-2948 Fax: (617)310-9948

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Substitute for form 1449B/PTO			-	Complete if Known		
				Application Number	09/922,973	
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STATEMENT BY APPLICANT				First Named Inventor	Theodore M. Bloomstein	
				Group Art Unit	1756	
	(use as many	sheets as	necessary)	Examiner Name	Kripa Sagar	
Sheet	1	of	1	Attorney Docket Number	101328-160	

U.S. PATENT DOCUMENTS							
Cite No.1	Document Number			Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear			
	Number-Kind Code <sup>2</sup> (if known)	MM-DD-YYYY	of Cited Document				
	5,182,056	01/26/1993	Spence et al.				
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	Cite No. 1	No.1 Number-Kind Code² (if known)	Cite Number-Kind Code <sup>2</sup> (il known) Publication Date MM-DD-YYYY	No. Number-Kind Code <sup>2</sup> (if known)  Number-Kind Code <sup>2</sup> (if known)			

OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS					
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.			
		Gale et al. "Fabrication of Continuous-relief micro-optical elements by direct laser writing in photoresists" <i>Optical Engineering</i> , vol. 33, no. 11, pgs. 3556-3566 (1994).			
		Chen et al. "Predicting total build-time and the resultant cure depth of the 3D stereolithography process" <i>Rapid Prototyping Journal</i> , vol. 2, no. 4, pgs. 27-40 (1996).			
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Examiner	Date	
Signature	Considered	

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<sup>&</sup>lt;sup>1</sup>Applicant's unique citation designation number (optional). <sup>2</sup>Applicant is to place a check mark here if English language Translation is attached.